# The Small Force Metrology Laboratory at the National Institute of Standards and Technology



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NIST

National Institute of Standards and Technology

Technology Administration, U.S. Department of Commerce

#### Background

### Evolution of SI traceable force at NIST

- SFML traceably measures microforces using a balance and transfer artifacts achieving nN resolution
- Molecular and atomic forces are one million times smaller





<u>Forces</u> Classical mass artifact

<u>Microforce</u> <u>Competence</u> <u>establishes SFML in</u> <u>FYO4</u> shift from deadweight paradigm by linking force to quantum invariants in electrical units

#### calibrated artifacts vs intrinsic forces



#### Intrinsic force competence starting FY06

Shift from calibrating artifacts to "calibrating" atomic and molecular interactions

Apply SI traceable electrical and optical forces directly to instruments

### Small forces in perspective

Background



SFML Calibration

## How do we calibrate a force?

• F=ma is a good start for a *deadweight* standard

Х



F=

Mass artifacts link to Kg



Gravitational acceleration linked to sec and meter

SFML calibration

# Deadweights for small force

 $F = mg \sim 10^{-5} N$ 



- Deadweight force realization is simple, accurate, and reliable down to 10<sup>-5</sup> N
- Accuracy: parts in 10<sup>4</sup>
- Many sensors (even some "nano") can be calibrated by suspending wires of known mass
- Limited by uncertainty in mass as we go smaller

# Calibrated indentation forces

 Deadweights used to calibrate standard force sensor



Traceable micro to millinewtons from NIST wire deadweight loader and modified Hysitron force cell

- Standard sensor used to calibrated indenter force
  - Discrepancies at low loads on order of few percent up to tens of percent depending on instrument



SFML calibration

# Smaller forces for AFM

 Realize forces below 10<sup>-5</sup> N through the electrical units as in Watt and Volt balances

Electrostatic Force = 
$$\frac{1}{2} \frac{dC}{dz} (Voltage^2)$$

- Disseminate through a calibrated "primary standard" force balance known as an EFB
  - Range: 10 nN 1 mN
  - Accuracy: parts in 10<sup>4</sup>
  - Resolution: < 1 nN

# What is the EFB?

- Compares unknown loads to an SI force derived from length, voltage, and capacitance
  - Diminutive cousin of the electronic Kg experiment!

Electrostatic Force = 
$$\frac{1}{2} \frac{dC}{dz} (Voltage^2)$$



### Calibrated AFM forces

- Most AFM systems use optical lever arms
- Calibrate spring constant (k) and optical lever sensitivity
- Accuracy is difficult to achieve...

#### **Measuring Spring Constants**

A word about precision:

#### Crappy

1-2 parts in 10 if you do everything right

Goals: InvOLS (nm/Volt) k (pN/nm) Crappy or better





Methods for determining k Thermal noise spectra Added mass Geometry and modulus Nanoindentation

To date, no approaches have had traceability

comparisons difficult

### EFB as instrumented indenter

• Calibrated cantilever reference springs can be used as AFM sensing elements or as reference standards for cantilever on cantilever calibrations



### NIST reference cantilever array

 Nominal stiffness values are determined from measurements of resonance frequency, geometry, bulk value of density, and beam bending theory using

 $k = 9.585 Lbt \rho f_{vac}^{2}$ 

 Absolute values are checked for quality control using NIST EFB in micro-cantilever stiffness calibrator mode



### Inter-comparison



- CMARS has proven well matched to EFB calibration
  - Size is convenient
  - Marks are clear and easy to hit
  - Access is a little difficult because of package
- Discrepancies exist between NPL published values and NIST EFB values
  - Undercut at cantilever base may be source of discrepancy

### EFB as force calibrator

• Use EFB as instrumented indenter and calibrate *force sensors,* just as at macroscale



### Force sensor calibration

- EFB instrumented indentation scheme measures absolute force and displacement required to move the balance suspension and any other spring in series with it
- Strain based sensors can be calibrated both as stiffness and force artifacts using the EFB instrumented indentation scheme, e.g., F vs d or F vs ohms
- New NIST sensor is being developed with piezoresistive strain element for force and or stiffness calibration (0.2 N/m to 12 N/m)



#### Future SI traceable picoforce realizations



$$F_E = \frac{1}{2} \frac{dC}{dz} \left( Voltage^2 \right)$$

Laser with optical power  $P_0$ 



- Need modestly accurate voltage, capacitance, and displacement metrology
- IF the geometry and field is well defined

- Photon momentum (6 pN/mW)
  - Need only modestly accurate optical power and reflectance metrology
  - IF heating and boiling off of molecules doesn't completely swamp the effect!

$$F_{p} = \frac{P_{0}}{c} (1+R) \cos(\phi)$$

#### Intrinsic forces?

#### Prototype intrinsic forces from nature



Break a gold nanocontact



Pull a biotin molecule from a streptavidin binding site



#### 1-2 nN

#### Break a single atomic bond

- Highest force, most difficult experiment
- Quantum conductance at break is a plus!

#### 100-200 pN

Rupture a binding site

• Rate dependent

35 & 65 pN *Change DNA* structure

0.2-65 pN *Stretch DNA* elastically

Summary

### Summary

- Small force measurement is a useful tool for nanomechanical characterization
- Small force metrology laboratory supports researchers in government, academia, and industry to calibrate small force measurements
  - SRM's are under development
  - We have calibrated instrumented indentation and AFM equipment
- Intrinsic standards may someday provide ready access to SI traceability for pN to nN measurements